



SP03-108

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: BELLMAN ROBERT

Examiner: To Be Assigned

Serial No: 10/646409

Group Art Unit: 1756

Filed: 8/22/2003

For: PROCESS FOR MAKING HARD
PELLICLESINFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. §§ 1.56, 1.97 – 1.98Commissioner of Patents
Alexandria, VA 22313-1450

Dear Sir:

The Examiner's attention is hereby directed to the following reference(s) listed on the attached Form PTO-1449 for consideration in connection with the examination of the above-identified patent application. One copy of the reference(s) is enclosed.

This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that each or all of the enclosed documents constitute "prior art." If it should be determined that any of the submitted documents do not constitute "prior art" under United States law, applicant(s) reserve the right to present to the office the relevant facts and law regarding the appropriate status of such documents.

Applicant(s) further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the enclosed references, should one or more of the references be applied against the claims of the present application.

The undersigned attorney has been granted limited recognition under 37 CFR 10.9(b) by the Office of Enrollment and Discipline to practice before the USPTO in capacity of an employee of Corning Incorporated. A copy of the document granting such limited recognition has been submitted previously.

Respectfully submitted,

Siwen Chen
Limited Recognition
Corning Incorporated
SP-TI-03-1
Corning, NY 14831
607-248-1253

Date: December 3, 2003

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to Commissioner of Patents, Alexandria, Va 22313-1450 on

12-3-03

Date of Deposit

Signature: Colleen E. Doherty



FORM PTO-1449 (MODIFIED)

ATTORNEY DOCKET NO.

SERIAL NO.

SP03-108

10/646409

LIST OF PATENTS AND
PUBLICATIONS
FOR APPLICANTS INFORMATION
DISCLOSURE STATEMENT

APPLICANT BELLMAN ROBERT

FILING DATE 8/22/2003

GROUP: 1756

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

Examiner Initial		Document Number	Date	Name	Class	Sub-Class	Filing Date if Approp.
	AA	6,466,365	10/15/02	Maier et al.	359	355	
	AB	6,475,575	11/5/02	Ikuta et al.	428	14	
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Sub-Class	Translation Yes	No
	AL							
	AM							
	AN							

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	AO	Jerry Cullins et al., 157 nm Photomask Handling and Infrastructure: Requirements and Feasibility, Proceedings of SPIE Vol. 4409 (2001) pages 632-640.
	AP	Eric P. Cotte et al., Dynamic Studies of Hard Pellicle Response During Exposure Scanning, J. Vac. Sci. Technol. B20(6), Nov/Dec 2002 pages 2995-2999.
	AQ	Encyclopedia of Chemical Technology, Volume 21, Recycling, Oil to Silicon, pages 750-763.
	AR	Andrew Grenville et al., International SEMATECH Hard Pellicle Task Force, July 3, 2002, pages 1-30.
	AS	Couillard et al., USSN 60/448,176, February 18, 2003, Glass-Based SOI Structures,
	AT	Encyclopedia of Chemical Technology, Liquid Crystalline Materials, Volume 15, Fourth Edition, pages 403-407.

EXAMINER:

DATE CONSIDERED:

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609: draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.